

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S57	2	"6203772".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/27 17:41
S58	31	tanino near2 kichiya.in. and (sic or silicon near2 carbide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/27 17:42
S59	29	tanino near2 kichiya.in. and (sic or silicon near2 carbide). ab.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/27 17:43
S60	2	"6203772".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/27 17:46
L3	217	("alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) and (beta or ".beta." or "3c") near15 (sic or silicon near2 carbide) near6 (film or layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:50

L2	136	("alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) same (beta or ".beta." or "3c") near15 (sic or silicon near2 carbide) near6 (film or layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:50
L1	31	tanino near2 kichiya.in. and (sic or silicon near2 carbide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:50
L6	67	(ring or annular \$6) near10 (sic or silicon near2 carbide) near10 (vapor near2 deposit\$5 or cvd)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:51
L5	361	("alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) same (beta or ".beta." or "3c") near15 (sic or silicon near2 carbide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:51
L4	519	("alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) and (beta or ".beta." or "3c") near15 (sic or silicon near2 carbide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:51

L8	25	(" .alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) same (beta or ".beta." or "3c") near15 (sic or silicon near2 carbide) and (grind\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:55
L7	195	(" .alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) and (beta or ".beta." or "3c") near15 (sic or silicon near2 carbide) and (grind\$5 or polish\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:55
L9	5	(" .alpha." or alpha or "6h") near10 (sic or silicon near2 carbide) near2 (wafer or substrate) same (poly or polycrystal\$6) near5 (sic or silicon near2 carbide) and (grind\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 09:57
L10	48	tanino.in. and (sic or silicon near2 carbide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 10:02
L11	4	("6053973" "6153165").pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/03/06 11:19

3/6/09 11:33:30 AM
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